



Photronics Promotes Richelle E. Burr to Vice President & General Counsel

BROOKFIELD, Conn., Jan 22, 2010 (BUSINESS WIRE) -- Photronics, Inc. (Nasdaq:PLAB), a worldwide leader in supplying innovative imaging technology solutions to the global electronics industry, is pleased to announce that Richelle E. Burr has been promoted to Vice President & General Counsel. Since 2003, Ms. Burr has acted in the role of Corporate Counsel for the company. She has over 18 years of business and corporate legal experience serving the semiconductor and industrial manufacturing industries. Ms. Burr's experience includes acquisitions and divestitures, international business transactions, finance and securities law.

Prior to joining Photronics, Ms. Burr was Assistant Joint Ventures Counsel as well as Securities and Finance Counsel for Union Carbide Corporation, where she provided general corporate legal advice on joint venture formations, corporate acquisitions and divestitures, Securities and Exchange Act filing reviews, as well as various financing transactions. Ms. Burr was also counsel to the polypropylene business and an international joint venture in Italy.

Ms. Burr earned her juris doctorate from Quinnipiac University School of Law and is a member of the Connecticut Bar.

Constantine ("Deno") Macricostas, Photronics' Chairman and Chief Executive Officer commented, "Ms. Burr's efforts and accomplishments have been instrumental for Photronics. Last fall, she provided the legal guidance necessary to lead our team through a successful stock and notes offering. Additionally, she continues to maneuver the complex international legal landscape as we migrate our global manufacturing network to match customer needs. Richelle has proven herself to be an integral member of our Executive Management Team."

About Photronics

Photronics is a leading worldwide manufacturer of photomasks. Photomasks are high precision quartz plates that contain microscopic images of electronic circuits. A key element in the manufacture of semiconductors and flat panel displays, photomasks are used to transfer circuit patterns onto semiconductor wafers and flat panel substrates during the fabrication of integrated circuits, a variety of flat panel displays and, to a lesser extent, other types of electrical and optical components. They are produced in accordance with product designs provided by customers at strategically located manufacturing facilities in Asia, Europe, and North America. Additional information on the Company can be accessed at www.photronics.com.

The Private Securities Litigation Reform Act of 1995 provides a "safe harbor" for forward-looking statements made by or on behalf of Photronics, Inc. and its subsidiaries (the Company). The forward-looking statements contained in this press release and other parts of Photronics' web site involve risks and uncertainties that may affect the Company's operations, markets, products, services, prices, and other factors as discussed in filings with the U. S. Securities and Exchange Commission (SEC). These risks and uncertainties include, but are not limited to, economic, competitive, legal, governmental, and technological factors. Accordingly, there is no assurance that the Company's expectations will be realized. The Company assumes no obligation to provide revisions to any forward-looking statements.

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SOURCE: Photronics, Inc.

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